

L Number	Hits	Search Text	DB	Time stamp
1	2	("6069243").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:30
2	0	((("6069243").PN.) and (tri adj1 chloroacetic)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:31
3	0	((("6069243").PN.) and ((trichloroacetic) (tri-chloroacetic))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:31
4	12685	trichloroacetic) (tri-chloroacetic	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:31
5	1152	(trichloroacetic) (tri-chloroacetic) and (deprotect\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:31
6	231	((trichloroacetic) (tri-chloroacetic) and (deprotect\$)) and (deprotect\$ same agent\$1)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:32
7	43	((trichloroacetic) (tri-chloroacetic) and (deprotect\$)) and (deprotect\$ same agent\$1)) and (acid same labile)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:36
8	155	((trichloroacetic) (tri-chloroacetic) and (deprotect\$)) and (deprotect\$ same ((trichloroacetic) (tri-chloroacetic)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:37
9	30	((trichloroacetic) (tri-chloroacetic) and (deprotect\$)) and (deprotect\$ same ((trichloroacetic) (tri-chloroacetic))) and (acid adj1 labile)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:38
10	0	((trichloroacetic) (tri-chloroacetic) and (deprotect\$)) and (deprotect\$ same ((trichloroacetic) (tri-chloroacetic))) and (acid adj1 labile)) and ((6%) same ((trichloroacetic) (tri-chloroacetic)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 18:39

L Number	Hits	Search Text	DB	Time stamp
1	57718	(array microarray chip biochip) same (fabricat\$ mak\$ synthesi\$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 12:06
2	515	((array microarray chip biochip) same (fabricat\$ mak\$ synthesi\$)) and ((protect\$ cap\$) same (oh hydroxy\$))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 12:10
3	0	((array microarray chip biochip) same (fabricat\$ mak\$ synthesi\$)) and ((protect\$ cap\$) same (oh hydroxy\$)) and (protect same (labile adj3 label\$))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 12:12
4	8	((array microarray chip biochip) same (fabricat\$ mak\$ synthesi\$)) and ((protect\$ cap\$) same (oh hydroxy\$)) and (protect same (acid adj3 labile))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 12:13
5	3	((array microarray chip biochip) same (fabricat\$ mak\$ synthesi\$)) and ((protect\$ cap\$) same (oh hydroxy\$)) and (protect same (acid adj3 labile)) and phosphite	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/03/06 12:13

FILE BIOSIS, MEDLINE, EMBASE, EMBAL, SCISEARCH, BIOTECHDS, CAPLUS'
ENTERED AT 15:54:38 ON 06 MAR 2002

L1 26322 S (ARRAY? OR BIOCHIP? MICROARRAY? CHIP?) AND
(FABRICAT? OR SYNT

L2 0 S L1 AND ((PROTECT? OR CAP?)(HYDROXY? OH?))

L3 3830 S L1 AND (PROTECT? OR CAP?)

L4 176 S L3 AND (HYDROXY?)

L5 7 S L4 AND (ACID()LABILE?)

L6 0 S L5 AND (PHOSPHITE?)

L7 6 DUP REM L5 (1 DUPLICATE REMOVED)

L7 ANSWER 1 OF 6 SCISEARCH COPYRIGHT 2002 ISI (R) DUPLICATE 1

ACCESSION NUMBER: 2000:198761 SCISEARCH

THE GENUINE ARTICLE: 290NB

TITLE: Reversible **protection** and reactive patterning of
amine- and **hydroxyl**-terminated self-assembled
monolayers on gold surfaces for the **fabrication**
of biopolymer **arrays**

AUTHOR: Frutos A G; Brockman J M; Corn R M (Reprint)

CORPORATE SOURCE: UNIV WISCONSIN, DEPT CHEM, 1101 UNIV AVE,
MADISON, WI

53706 (Reprint); UNIV WISCONSIN, DEPT CHEM, MADISON, WI
53706

COUNTRY OF AUTHOR: USA

SOURCE: LANGMUIR, (7 MAR 2000) Vol. 16, No. 5, pp. 2192-2197.

Publisher: AMER CHEMICAL SOC, 1155 16TH ST, NW,
WASHINGTON, DC 20036.

ISSN: 0743-7463.

DOCUMENT TYPE: Article; Journal

FILE SEGMENT: PHYS

LANGUAGE: English

REFERENCE COUNT: 37

ABSTRACT IS AVAILABLE IN THE ALL AND IALL FORMATS

AB The reversible **protection** of amine- and **hydroxyl**
-terminated alkanethiol self-assembled monolayers (SAMs) on gold surfaces
using the base-**labile protecting** group 9-
fluorenylmethoxycarbonyl (Fmoc) and the **acid-labile**
protecting group dimethoxytrityl (DMT) is described. When used in
combination with UV photopatterning or mu-contact printing techniques, this
reversible SAM **protection** chemistry can be used to control the
reactivity and wettability of different portions of the surface. Such
spatial control is utilized in the **fabrication** of DNA
arrays. Specifically, gold surfaces modified with the
amine-terminated alkanethiol 11-mercaptoundecylamine (MUAM) are reacted
with an N-**hydroxysuccinimide** (NHS) ester derivative of Fmoc,
forming a covalent urethane (carbamate) linkage and converting the

initially hydrophilic MUAM surface to a hydrophobic, Fmoc-terminated surface. Upon exposure of the Fmoc-modified surface to a solution of a secondary amine, the Fmoc is cleaved, regenerating the original hydrophilic MUAM surface. Fmoc is also utilized as a **hydroxyl protecting** group, as demonstrated by the reaction of Fmoc-Cl with a monolayer of 11-mercaptoundecanol (MUD). The hydrophobic **protecting** group DMT is reacted with the w-**hydroxyl** groups of both MUD and poly(ethylene glycol)-terminated alkanethiol (PEG-SH) SAMs to form an **acid labile** ether bond; removal of the DMT group is accomplished by soaking the surface in 3% trifluoroacetic **acid**. A combination of polarization-modulation Fourier transform infrared reflection absorption spectroscopy (PM-FTIRAS), surface plasmon resonance (SPR), and contact angle measurements is used to characterize the attachment and subsequent removal of the **protecting** groups. To demonstrate one application of this SAM **protection** chemistry and reactive patterning, a DNA **array** is **fabricated** and used in an SPR imaging measurement of the adsorption of the mismatch binding protein MutS.

L7 ANSWER 2 OF 6 CAPLUS COPYRIGHT 2002 ACS

ACCESSION NUMBER: 2000:795794 CAPLUS

TITLE: Automated solid-phase **synthesis** of linear metallo-assemblies.

AUTHOR(S): Filocamo, Shaun S.; Tierney, Mark T.; Grinstaff, Mark W.

CORPORATE SOURCE: Department of Chemistry, Duke University, Durham, NC, 27708, USA

SOURCE: Abstr. Pap. - Am. Chem. Soc. (2000), 220th, INOR-348
CODEN: ACSRAL; ISSN: 0065-7727

PUBLISHER: American Chemical Society

DOCUMENT TYPE: Journal; Meeting Abstract

LANGUAGE: English

AB Assembling metal complexes in ordered **arrays** is of interest for applications ranging from light harvesting to mol. electronic devices. Many of the current soln.-phase strategies to **synthesize** metallodendrimers use the metal ion as a supramol. "glue" to link together the dendrimer units through coordination. Our strategy differs in that we will use solid-phase **synthetic** strategies to assemble metal complexes together via a phosphate linkage. We are applying the concepts previously developed for DNA **synthesis** to problems of material science whereby we construct highly regular and tunable metallo-dendrimers and metallo-chains. The first step requires **synthesizing** a Ru(diimine)₃²⁺ complex contg. both a primary and secondary **hydroxyl** group. The primary **hydroxyl** is subsequently **protecting** with an **acid labile** **protecting** group (DMT) and the secondary is activated for

phosphate coupling with cyanoethyl diisopropylchlorophosphoramidite. Using this novel Ru complex in a DNA solid phase synthesizer affords the ruthenium chain shown below.

L7 ANSWER 3 OF 6 CAPLUS COPYRIGHT 2002 ACS

ACCESSION NUMBER: 1997:252551 CAPLUS

DOCUMENT NUMBER: 126:336736

TITLE: Chemically amplified photolithography for the
**fabrication of high density oligonucleotide
arrays**

AUTHOR(S): Beecher, Jody E.; McGall, Glenn H.; Goldberg, Martin
J.

CORPORATE SOURCE: Affymetrix, Santa Clara, CA, 95051, USA
SOURCE: Polym. Mater. Sci. Eng. (1997), 76, 597-598

CODEN: PMSEDG; ISSN: 0743-0515

PUBLISHER: American Chemical Society

DOCUMENT TYPE: Journal

LANGUAGE: English

AB A chem. amplified photoimaging process for the **fabrication** of high d. oligonucleotide **arrays** is developed. The process utilizes light to generate **acid** within a polymer coating to remove **acid-labile** dimethoxytrityl (DMT) **protecting** groups on the 5' **hydroxyl** of the growing oligonucleotide. After application of the polymer film to the substrate, selective exposure produces **acid** in defined regions. The **acid** then effects the **deprotection** of the oligonucleotide chain, allowing for specific coupling in the next growth step (after photoresist stripping).

L7 ANSWER 4 OF 6 CAPLUS COPYRIGHT 2002 ACS

ACCESSION NUMBER: 1997:163915 CAPLUS

TITLE: Chemically amplified photolithography for the
**fabrication of high density oligonucleotide
arrays.**

AUTHOR(S): Beecher, Jody E.; McGall, Glenn H.; Goldberg, Martin
J.

CORPORATE SOURCE: Affymetrix, Santa Clara, CA, 95051, USA

SOURCE: Book of Abstracts, 213th ACS National Meeting, San
Francisco, April 13-17 (1997), PMSE-358. American
Chemical Society: Washington, D. C.
CODEN: 64AOAA

DOCUMENT TYPE: Conference; Meeting Abstract

LANGUAGE: English

AB We have developed a chem. amplified photo process for the **fabrication** of high d. oligonucleotide **arrays**. Using photolithog. and chem. amplification to generate **acid** within a polymer coating, the **acid-labile protecting** groups

on the 5' **hydroxyl** of the growing oligonucleotide can be selectively removed, allowing for site specific coupling in the next growth step. The process can be tuned to have high sensitivity (20 mJ/cm²) or high contrast (.apprx.3.0) and has been used to **synthesize** oligonucleotides on a glass substrate in relatively high yields.

L7 ANSWER 5 OF 6 CAPLUS COPYRIGHT 2002 ACS

ACCESSION NUMBER: 1997:488686 CAPLUS

TITLE: The solid phase **synthesis** of trisubstituted 1,4-diazabicyclo[4.3.0]nonan-2-one scaffolds via an intramolecular mitsunobu reaction.

AUTHOR(S): Swayze, Eric E.; Tinder, Robert

CORPORATE SOURCE: Department Medicinal Chemistry, Isis Pharmaceuticals, Carlsbad, CA, 92008, USA

SOURCE: Book of Abstracts, 214th ACS National Meeting, Las Vegas, NV, September 7-11 (1997), ORGN-286. American Chemical Society: Washington, D. C.
CODEN: 64RNAO

DOCUMENT TYPE: Conference; Meeting Abstract

LANGUAGE: English

AB: A representative series of 3,4,8-trisubstituted 1,4-diazabicyclo[3.4.0]nonan-2-ones has been prepd. on an automated parallel **array synthesizer** employing solid phase methodologies. A **protected 4-hydroxyproline** deriv. was attached to solid support via an **acid labile** amide linker. Elaboration off the proline nitrogen with an amino **acid** deriv., followed by an intramol. Mitsunobu cyclization provided the desired heterocycle, which could be further functionalized at the 4-position. The three chiral centers in the scaffold are derived from amino **acid** starting materials, allowing the **synthesis** of any isomer desired. This **synthetic** method proved to be both facile and general, and is suitable for the construction of large libraries of compds. for biol. assays. Complete **synthetic** details, including model soln. phase studies, solid phase development work, and automated parallel **synthesis** of representative compds. will be presented.

L7 ANSWER 6 OF 6 BIOTECHDS COPYRIGHT 2002 DERWENT INFORMATION LTD

ACCESSION NUMBER: 1997-13050 BIOTECHDS

TITLE: Chemically amplified photolithography for the **fabrication** of high density oligonucleotide **arrays**;

e.g. DNA probe **array synthesis** on an adsorbent (conference abstract)

AUTHOR: Beecher J E; McGall G H; Goldberg M J